UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|------------------------------------|-------------------------|----------------------|---------------------|------------------|
| 10/532,564 | 08/17/2005 | Yasuhiro Saito | 16169.4 | 6718 |
| 22913 Workman Nyde | 7590 01/08/200 egger | 9 | EXAMINER | |
| 1000 Eagle Gat | e Tower | GRANT, ALVIN J | | |
| 60 East South T Salt Lake City, | | | ART UNIT | PAPER NUMBER |
| • | | | 3723 | |
| | | | | |
| | | | MAIL DATE | DELIVERY MODE |
| | | | 01/08/2009 | PAPER |

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

| | Application No. | Applicant(s) |
|---|---|--|
| | 10/532,564 | SAITO ET AL. |
| Office Action Summary | Examiner | Art Unit |
| | ALVIN J. GRANT | 3723 |
| The MAILING DATE of this communication ap Period for Reply | ppears on the cover sheet with the | correspondence address |
| A SHORTENED STATUTORY PERIOD FOR REP WHICHEVER IS LONGER, FROM THE MAILING I - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory perior Failure to reply within the set or extended period for reply will, by statu. Any reply received by the Office later than three months after the mail earned patent term adjustment. See 37 CFR 1.704(b). | DATE OF THIS COMMUNICATIO 1.136(a). In no event, however, may a reply be ti d will apply and will expire SIX (6) MONTHS from the, cause the application to become ABANDONE | N. mely filed the mailing date of this communication. ED (35 U.S.C. § 133). |
| Status | | |
| 1) ☐ Responsive to communication(s) filed on 30 2a) ☐ This action is FINAL . 2b) ☐ Th 3) ☐ Since this application is in condition for allow closed in accordance with the practice under | nis action is non-final. vance except for formal matters, pr | |
| Disposition of Claims | | |
| 4) Claim(s) 1-18 is/are pending in the application 4a) Of the above claim(s) 1-6 is/are withdraw 5) Claim(s) 8 and 11-20 is/are allowed. 6) Claim(s) 7,9 and 10 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and application Papers 9) The specification is objected to by the Examing 10) The drawing(s) filed on is/are: a) according to the specification to the spec | n from consideration. /or election requirement. ner. ccepted or b) □ objected to by the | |
| Applicant may not request that any objection to th Replacement drawing sheet(s) including the corre | ection is required if the drawing(s) is ob | pjected to. See 37 CFR 1.121(d). |
| Priority under 35 U.S.C. § 119 | | |
| 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document of: 2. Certified copies of the priority document of: 3. Copies of the certified copies of the priority document of the priority document of the certified copies of the c | nts have been received. nts have been received in Applicat iority documents have been receiv au (PCT Rule 17.2(a)). | ion No ed in this National Stage |
| Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date | 4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal I 6) Other: | ate |

Application/Control Number: 10/532,564 Page 2

Art Unit: 3723

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

2. Claims 7 and 9 are rejected under 35 U.S.C. 102(b) as being anticipated by Saito et al. 2003/0110803.

Saito discloses a method for manufacturing a glass substrate for an information recording medium, the manufacturing method comprising: a first washing step for washing a surface of a disk-shaped glass plate with an acid washing liquid (¶0057, line 1; and (¶0059), wherein an altered surface layer is formed on the surface of the glass substrate by the first washing step; a step for grinding at least part of the altered surface layer with abrasion grains to remove at least part of the altered surface layer (¶0057 and (¶0058); and a second washing step for washing the surface with an alkaline washing liquid (¶0058, line 12), wherein the altered surface layer formed by acidic washing in the first washing step is removed by the step for grinding and the second washing step.

Claim Rejections - 35 USC § 103

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

Application/Control Number: 10/532,564 Page 3

Art Unit: 3723

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

4. **Claim 10** is rejected under 35 U.S.C. 103(a) as being unpatentable over Saito et al. in view of Matsuno et al. 2003/0109202.

Saito et al. is described above. Saito et al. does not specifically disclose the first washing step including immersing the glass plate in a strong acid solution and then immersing the glass plate in a strong alkaline solution. Matsuno et al. discloses a discloses a method for manufacturing a glass substrate wherein the first washing step comprises immersing the glass plate in a strong acid solution and then immersing the glass plate in a strong alkaline solution so as to thoroughly remove the (projecting) layer that has been altered by the acidic solution. It would have been obvious to one having ordinary skill in the art at the time the invention was made to have made the apparatus of Saito et al. to have immersed the glass plate in a strong acid solution and then immerse the glass plate in a strong alkaline solution as taught by Matsuno et al. so as to thoroughly remove the (projecting) layer that has been altered by the acidic solution.

Allowable Subject Matter

5. Claims 8 and 11-18 are allowed.

Response to Arguments

6. Applicant's arguments with respect to claims 7, 9 and 10 have been considered but are moot. The reason being that although US Patent No. 2003/0110803 to Saito et al. discloses the claimed method steps, the paragraphs were cited were incorrect.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to ALVIN J. GRANT whose telephone number is (571)272-4484. The examiner can normally be reached on Mon-Fri 8:00-4:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Joseph J. Hail can be reached on (571) 272-4485. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Alvin J Grant/ Examiner, Art Unit 3723 Application/Control Number: 10/532,564

Page 5

Art Unit: 3723